IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of

Applicant : Gurtej S. Sandhu Serial No. : 10/765,314

Filed : January 27, 2004

Title : ATOMIC LAYER DEPOSITION WITH POINT OF USE GENERATED

REACTIVE GAS SPECIES

Docket : MIO 0092 NA

Examiner : Smith, Francis P.

Art Unit : 1792 Confirm. No. : 9407

EFS WEB ELECTRONIC SUBMISSION

September 9, 2008

MAIL STOP ISSUE FEE Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir

AMENDMENT UNDER 37 CFR 1.312

This paper is being filed to update the cross-reference data after allowance. Consideration of the present application is respectfully requested in light of the amendments and remarks below, which include, in order of appearance, beginning on separate sheets:

- · Amendments to the Specification; and
- Remarks.